**Erratum: Photothermal Engineering of Graphene Plasmons
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A typo at the end of the second page of this Letter affects the approximate expression for the temperature-dependent graphene chemical potential. The correct expression is $\mu = E_F[(1 + \xi^2)^{1/2} - \xi]^{1/2}$, with $\xi = (2 \log^2 4)(k_B T_e / E_F)^2$, where E_F is the zero-temperature Fermi energy, T_e is the electronic temperature, and k_B is the Boltzmann constant. Calculations in the Letter are not affected, as they are carried out using this corrected expression.